

# Magnetic properties of Au/Co/Ni<sub>80</sub>Fe<sub>20</sub>/Co/Au layered structures

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Magnetic thin film layered structures characterized by new magnetic properties are desirable for applications in spintronic devices. This contribution concerns the magnetic properties of Co/Ni<sub>80</sub>Fe<sub>20</sub>/Co trilayers sandwiched between gold layers. The main goal of this study was to develop a thin film system, characterized by easy plane anisotropy, in which the effective anisotropy field  $H_K^{\text{eff}}$  (the saturation field for the perpendicular configuration) can be simply tailored in a wide range. This can be realized for systems having a strong perpendicular surface anisotropy, *e.g.* in Au/Co/Au layered systems. In such films, due to the competition between the shape and surface anisotropy,  $H_K^{\text{eff}}$  monotonically increases with the Co thickness for  $t_{\text{Co}} > t_{\text{crit}}$  ( $t_{\text{crit}}$  - critical cobalt thickness corresponding to the spin reorientation transition). The substitution of a single Co layer in the Au/Co/Au structure by Co/Ni<sub>80</sub>Fe<sub>20</sub>/Co trilayer strongly modifies the effective anisotropy. In particular, a thin permalloy layer introduced in the middle of cobalt layer reduces  $t_{\text{crit}}$  and results in growth of  $H_K^{\text{eff}}$  (Fig. 1). We will discuss application of Au/Co/Ni<sub>80</sub>Fe<sub>20</sub>/Co/Au structures with different values of  $H_K^{\text{eff}}$ , for modification of the magnetoresistance characteristics ( $R(H)$  dependencies) in GMR layered films (for preliminary results see [1]).

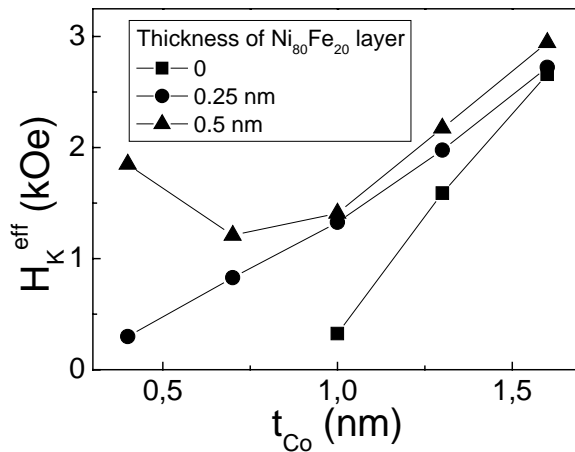


Fig. 1. Effective anisotropy field  $H_K^{\text{eff}}$  of Au/Co/Ni<sub>80</sub>Fe<sub>20</sub>/Co/Au films as a function of the total thickness of Co layers and different thickness of permalloy layer.

[1] F. Stobiecki *et al.*, *phys. stat. sol. (b)* **243** (2006) 210.

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